

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	2	10/115208	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/04/01 13:01
L2	52	((438/3,239,650,686).CCLS.) and conduct\$3 adj layer) and(conduct\$3 adj layer) with metal near3 oxide and capacitor	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/04/01 15:15
L3	183	(lower bottom) near2 electrode with (platinum near2 oxide)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/04/01 13:03
L4	26	(lower bottom) near2 electrode with (platinum adj oxide)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/04/01 13:03
L5	13	(lower bottom) near2 electrode with (platinum adj oxide) with (Ir iridium) and iridium near3 oxide	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/04/01 14:47
L6	2	("6713808").PN.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/04/01 14:11
L7	26	(lower bottom) near2 electrode with (platinum adj oxide)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/04/01 14:49
L8	13	7 not 5	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/04/01 14:47
L9	0	(lower bottom) near2 (electrodenear structure) with (platinum adj oxide)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/04/01 14:51

L10	0	(lower bottom) near2 (electrode near structure) with (platinum adj oxide)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/04/01 14:49
L11	0	(lower bottom) near2 (electrode near stacking) with (platinum adj oxide)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/04/01 14:51
L12	6	(lower bottom) near2 (electrode near stacking)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/04/01 16:02
L13	2171	(257/295,310).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/04/01 15:00
L14	47	13 and conduct\$3 adj layer and (conduct\$3 adj layer) with metal near3 oxide and capacitor	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/04/01 15:00
L15	56	((438/3,239,381,650,686).CCLS.) and conduct\$3 adj layer) and(conduct\$3 adj layer) with metal near3 oxide and capacitor	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/04/01 16:02
L19	0	l15 and (lower bottom) near5 (electrode near stacking)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/04/01 16:03
L20	0	l15 and (lower bottom) with (electrode near stacking)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/04/01 16:03
L21	0	l15 and (lower bottom) same (electrode near stacking)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/04/01 16:03
L23	47	l15 and (lower bottom) near electrode	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/04/01 16:04